

# **R&D Plan in FY2003**

Vertex Detector Subgroup

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# Activity in FY2002

## ■ Development of CPCI ADC

- Design has been completed
- Modules will delivered in this summer

## ■ Radiation Damage Study

- High energy (150MeV) electron irradiation at Tohoku Univ.
- Sr-90 irradiation at KEK
- $6 \times 10^{10}$  /cm<sup>2</sup> electrons irradiated in both cases
- 150MeV electrons have x3 (not x10) larger effect

# Activity Plan in FY2003

- CCD Radiation Damage Study
- Development of CPCI ADC
- Study of Thin CCD Wafer
- Study of Diffusion in Epitaxial Layer
- Simulation

# CCD Radiation Damage Study

- Irradiation of HE electrons
  - 1 shift x 4 machine times ( up to  $10^{12}/\text{cm}^2$ )
  - More accurate and reliable dose monitor
- Irradiation of Sr-90  $\beta$ 
  - Same dose as HE electron irradiation
  - Reliable comparison with HE irradiation

# CCD Radiation Damage Study (Cont.)

- Study of characteristics of irradiated CCDs
  - $I_d$  vs. Temp
  - Flat-band Voltage Shift
  - CTI vs. Temp
  - CTI vs. Readout frequency
  - CTI vs. Fat-zero charge
  - CTI vs. clock pulse width/height
  - $\sigma_x$  vs. dose
  - E-dependence of items listed above
  - Annealing/anti-annealing

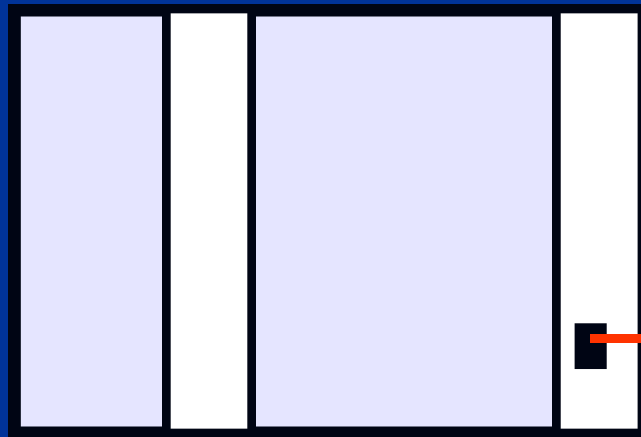
# Development of CPCI ADC

- Get CPCI ADC Modules from company
  - Planned in August
- CCD Timing Circuit
  - Use FPGA
  - Generate drive pulses for CCD (TTL) and clock pulses for CPCI ADC (LVDS)
- Construction of CPCI DAQ system

# CPCI DAQ System

## ■ Example

Compact PCI Crate (6U)



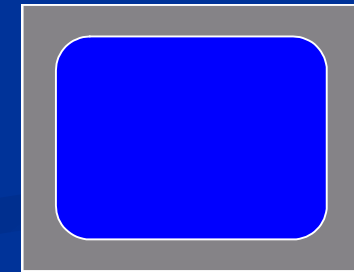
ADC

CPU Card

Gbit Hub



Host PC  
with Gbit NIC



# Study of Thin CCD Wafer

## ■ Motivation

- CCDs have  $\sim 20\mu\text{m}$  thick sensitive region
- Should be thinned to  $\sim 20\mu\text{m}$  if mechanical strength is ensured

## ■ Sample Wafers

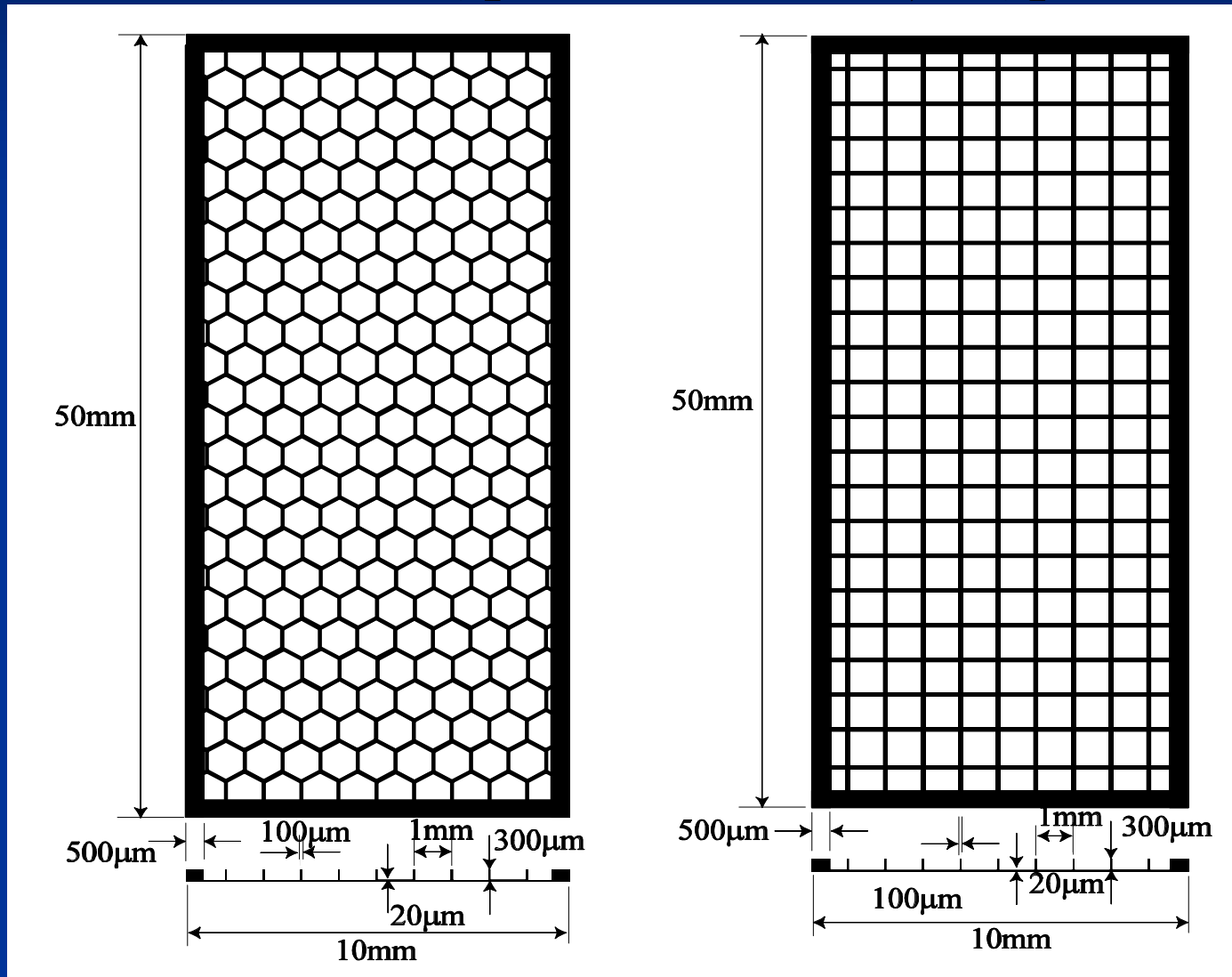
- Picture frame type ---- No good
- Honeycomb/SHOJI type will be studied
  - Strength calculation with ANSYS
  - If OK, make sample wafers



# Sample Wafer

■ Honeycomb Type

■ Shouji Type



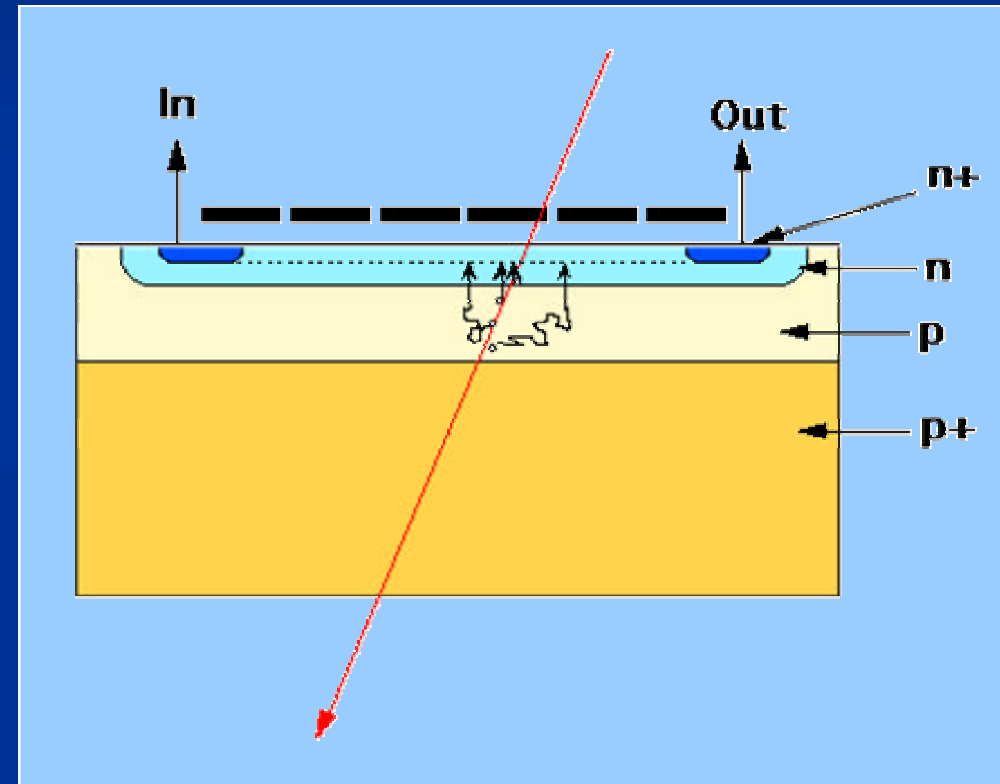
Average  
thickness

= 76μm

= 100μm  
(including  
edge)

# Study of Diffusion in Epi-Layer

- Diffusion of electrons in Epi. Layer
  - Key of excellent spatial resolution for CCD & CMOS pixel sensors
  - Takes time to diffuse
    - $d = \text{sqrt}(Dt)$
    - $d \sim 6\mu\text{m}$  @  $t=10\text{ns}$
    - ⇒ May not work at TESLA
- Measure charge spread as a function of time



# Simulation

- Simulation studies concerning Vertex det.
  - Background study using Full Simulator (JIM, JUPITER) -  
- Sugimoto, Aso
  - Physics study using Quick Simulator -- G.B. Yu
  - Physics and Detector study using Full Simulator

# Future dream in FY2004~

- Custom made CCDs with
  - > 20MHz readout speed
  - Multiple readout nodes
  - Notch structure
  - Charge injection capability
  - Readout by ASIC with multi-channel CDSs, Amplifiers, ADCs, and a Multiplexer
- Things to do in 2003
  - Technical design of the prototype CCD ( with HPK)
  - Try to get ¥ -- Japan-US, KAKENHI, etc.